

**REPETITIVE AVALANCHE AND dv/dt RATED
HEXFET® TRANSISTOR**

IRHNB7264SE

N-CHANNEL
SINGLE EVENT EFFECT (SEE) RAD HARD

250Volt, 0.11W, (SEE) RAD HARD HEXFET

International Rectifier's (SEE) RAD HARD technology HEXFETs demonstrate immunity to SEE failure. No compensation in gate drive circuitry is required. These devices are also capable of surviving transient ionization pulses as high as 1×10^{12} Rads (Si)/Sec, and return to normal operation within a few microseconds. Since the SEE process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters. They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

Product Summary

Part Number	BVDSS	RDS(on)	ID
IRHNB7264SE	250V	0.11W	34A

Features:

- Radiation Hardened up to 1×10^5 Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Surface Mount
- Lightweight

Absolute Maximum Ratings

Pre-Irradiation

	Parameter	IRHNB7264SE	Units
ID @ VGS = 12V, TC = 25°C	Continuous Drain Current	34	A
ID @ VGS = 12V, TC = 100°C	Continuous Drain Current	21	
IDM	Pulsed Drain Current ①	136	
PD @ TC = 25°C	Max. Power Dissipation	300	W
	Linear Derating Factor	2.4	W/°C
VGS	Gate-to-Source Voltage	±20	V
EAS	Single Pulse Avalanche Energy ②	500	mJ
IAR	Avalanche Current ①	34	A
EAR	Repetitive Avalanche Energy ①	30	mJ
dv/dt	Peak Diode Recovery dv/dt ③	2.5	V/ns
TJ	Operating Junction	-55 to 150	°C
TSTG	Storage Temperature Range		
	Package Mounting Surface Temperature	300 (for 5 sec.)	
	Weight	3.5 (typical)	g

Electrical Characteristics @ $T_J = 25^\circ\text{C}$ (Unless Otherwise Specified)

Parameter		Min	Typ	Max	Units	Test Conditions
BVDSS	Drain-to-Source Breakdown Voltage	250	—	—	V	$V_{GS} = 0\text{V}, I_D = 1.0\text{mA}$
$\Delta BVDSS/\Delta T_J$	Temperature Coefficient of Breakdown Voltage	—	0.32	—	V/ $^\circ\text{C}$	Reference to 25°C , $I_D = 1.0\text{mA}$
$R_{DS(on)}$	Static Drain-to-Source On-State Resistance	—	—	0.110	W	$V_{GS} = 12\text{V}, I_D = 21\text{A}$ ④
		—	—	0.123		$V_{GS} = 12\text{V}, I_D = 34\text{A}$
$V_{GS(th)}$	Gate Threshold Voltage	2.5	—	4.5	V	$V_{DS} = V_{GS}, I_D = 1.0\text{mA}$
g_{fs}	Forward Transconductance	10	—	—	S (M)	$V_{DS} > 15\text{V}, I_{DS} = 21\text{A}$ ④
I_{DSS}	Zero Gate Voltage Drain Current	—	—	50	mA	$V_{DS} = 0.8 \times \text{Max Rating}, V_{GS}=0\text{V}$
		—	—	250		$V_{DS} = 0.8 \times \text{Max Rating}$ $V_{GS} = 0\text{V}, T_J = 125^\circ\text{C}$
I_{GSS}	Gate-to-Source Leakage Forward	—	—	100	nA	$V_{GS} = 20\text{V}$
I_{GSS}	Gate-to-Source Leakage Reverse	—	—	-100		$V_{GS} = -20\text{V}$
Q_g	Total Gate Charge	—	—	220	nC	$V_{GS} = 12\text{V}, I_D = 34\text{A}$
Q_{gs}	Gate-to-Source Charge	—	—	50		$V_{DS} = \text{Max Rating} \times 0.5$
Q_{gd}	Gate-to-Drain ('Miller') Charge	—	—	110		
$t_{d(on)}$	Turn-On Delay Time	—	—	35	ns	$V_{DD} = 125\text{V}, I_D = 34\text{A},$ $R_G = 2.35\text{W}$
t_r	Rise Time	—	—	180		
$t_{d(off)}$	Turn-Off Delay Time	—	—	100		
t_f	Fall Time	—	—	120		
L _D	Internal Drain Inductance	—	0.8	—	nH	Measured from drain lead, 6mm (0.25 in) from package to center of die.
L _S	Internal Source Inductance	—	2.8	—		
C _{iss}	Input Capacitance	—	4000	—	pF	$V_{GS} = 0\text{V}, V_{DS} = 25\text{V}$ $f = 1.0\text{MHz}$
C _{oss}	Output Capacitance	—	1300	—		
C _{rss}	Reverse Transfer Capacitance	—	480	—		

Source-Drain Diode Ratings and Characteristics

Parameter		Min	Typ	Max	Units	Test Conditions
I _S	Continuous Source Current (Body Diode)	—	—	34	A	Modified MOSFET symbol showing the integral reverse p-n junction rectifier.
I _{SM}	Pulse Source Current (Body Diode) ①	—	—	136		
V _{SD}	Diode Forward Voltage	—	—	1.4	V	$T_J = 25^\circ\text{C}, I_S = 34\text{A}, V_{GS} = 0\text{V}$ ④
t_{rr}	Reverse Recovery Time	—	—	700	ns	$T_J = 25^\circ\text{C}, I_F = 34\text{A}, dI/dt \leq 100\text{A/ms}$
Q _{RR}	Reverse Recovery Charge	—	—	16	mC	$V_{DD} \leq 50\text{V}$ ④
t_{on}	Forward Turn-On Time	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by L _S + L _D .				

**Thermal Resistance**

Parameter		Min	Typ	Max	Units	Test Conditions
R _{thJC}	Junction-to-Case	—	—	0.42	°C/W	Soldered to a 1" sp. copper-clad board
R _{thJ-PCB}	Junction-to PC board	—	1.6	—		

Radiation Performance of Rad Hard HEXFETs

International Rectifier Radiation Hardened HEXFETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier comprises 3 radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019 condition A. International Rectifier has imposed a standard gate condition of 12 volts per note 5 and a V_{DS} bias condition equal to 80% of the device rated voltage per note 6. Post-irradiation limits of the devices irradiated to 1×10^5 Rads (Si) are presented in Table 1, column 1, IRHNB7264SE. The values in Table 1 will be met for either of the two low

dose rate test circuits that are used. Both pre- and post-irradiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison. It should be noted that at a radiation level of 1×10^5 Rads (Si) the only parameter limit change is V_{GSTh} minimum.

High dose rate testing may be done on a special request basis using a dose rate up to 1×10^{12} Rads (Si)/Sec. (See Table 2)

International Rectifier radiation hardened HEXFETs have been characterized in heavy ion Single Event Effects (SEE) environments. Single Event Effects characterization is shown in Table 3.

Table 1. Low Dose Rate ⑤ ⑥

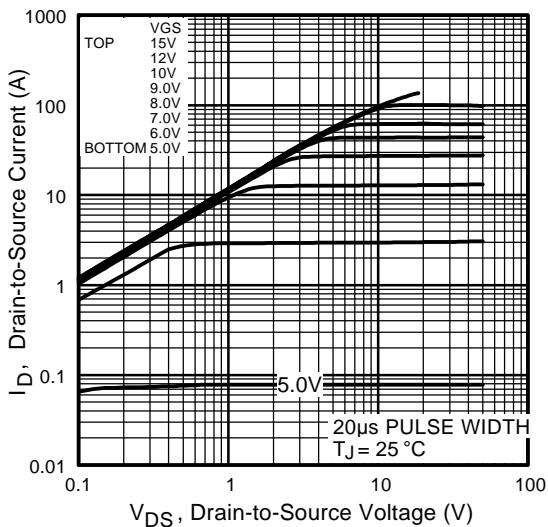
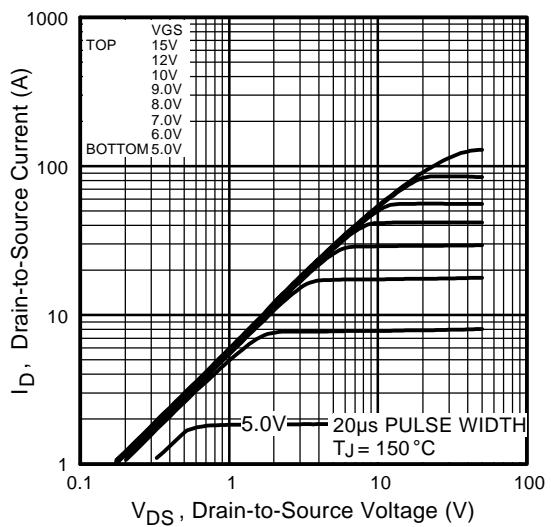
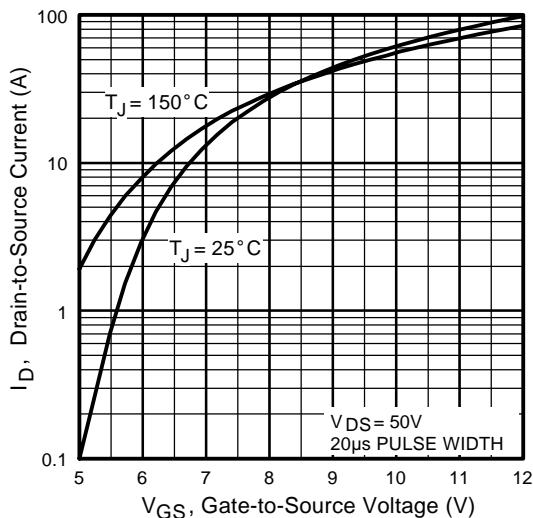
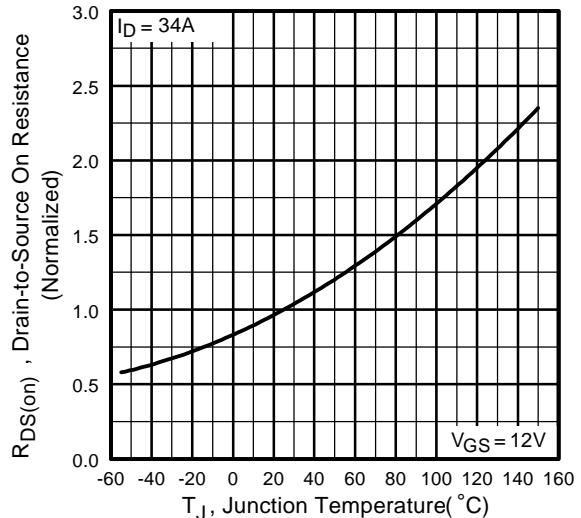
Parameter	IRHNB7264SE	100K Rads (Si)		Units	Test Conditions
		Min	Max		
BV_{DSS}	Drain-to-Source Breakdown Voltage	250	—	V	$V_{GS} = 0V, I_D = 1.0mA$
$V_{GS(th)}$	Gate Threshold Voltage ④	2.0	4.5		$V_{GS} = V_{DS}, I_D = 1.0mA$
I_{GSS}	Gate-to-Source Leakage Forward	—	100	nA	$V_{GS} = 20V$
I_{GSS}	Gate-to-Source Leakage Reverse	—	-100		$V_{GS} = -20V$
I_{DSS}	Zero Gate Voltage Drain Current	—	50	μA	$V_{DS}=0.8 \times \text{Max Rating}, V_{GS}=0V$
$R_{DS(on)1}$	Static Drain-to-Source ④ On-State Resistance One	—	0.110	W	$V_{GS} = 12V, I_D = 21A$
V_{SD}	Diode Forward Voltage ④	—	1.4	V	$T_C = 25^\circ C, I_S = 34A, V_{GS} = 0V$

Table 2. High Dose Rate ⑦

Parameter	10 ¹¹ Rads (Si)/sec	10 ¹² Rads (Si)/sec			Units	Test Conditions
		Min	Typ	Max		
V_{DSS}	Drain-to-Source Voltage	—	—	200	—	—
I_{PP}		—	10	—	—	Applied drain-to-source voltage during gamma-dot
di/dt		—	16	—	—	Peak radiation induced photo-current
L_1		—	1.0	—	—	Rate of rise of photo-current
		—	—	120	—	μH
		—	—	—	—	Circuit inductance required to limit di/dt

Table 3. Single Event Effects

Ion	LET (Si) (MeV/mg/cm ²)	Fluence (ions/cm ²)	Range (μm)	V_{DS} Bias (V)	V_{GS} Bias (V)
Cu	28	3×10^5	43	250	-5

**Fig 1.** Typical Output Characteristics**Fig 2.** Typical Output Characteristics**Fig 3.** Typical Transfer Characteristics**Fig 4.** Normalized On-Resistance Vs. Temperature

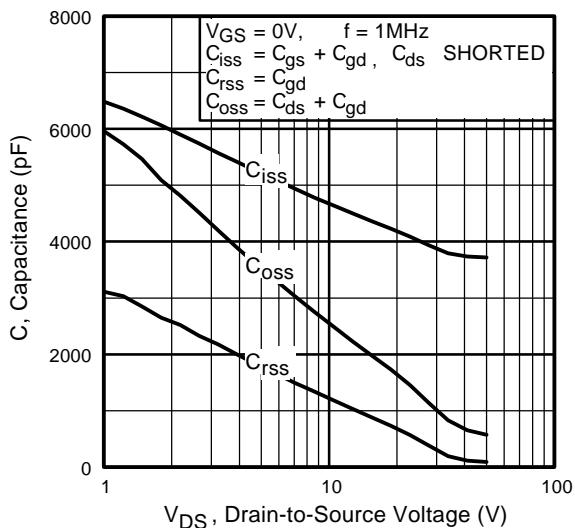


Fig 5. Typical Capacitance Vs.
Drain-to-Source Voltage

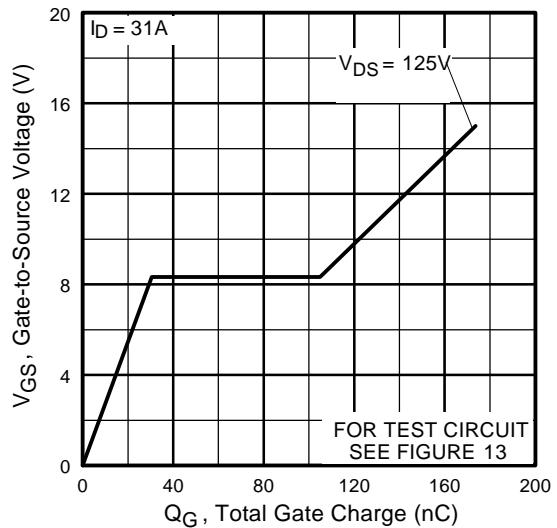


Fig 6. Typical Gate Charge Vs.
Gate-to-Source Voltage

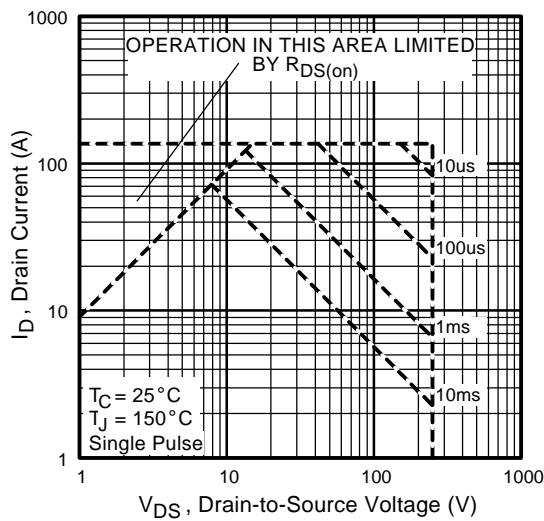


Fig 7. Maximum Safe Operating Area

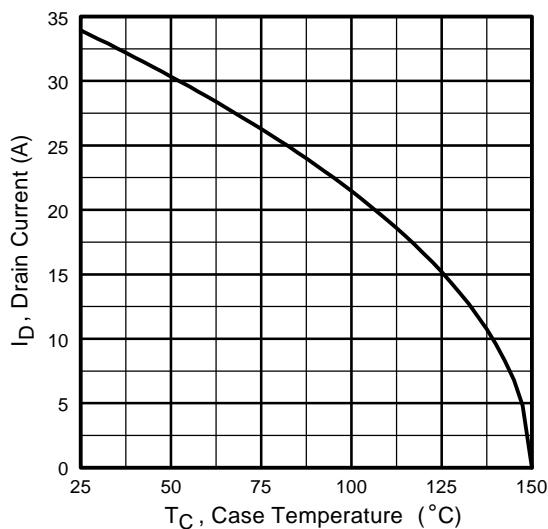


Fig 8. Maximum Drain Current Vs.
Case Temperature

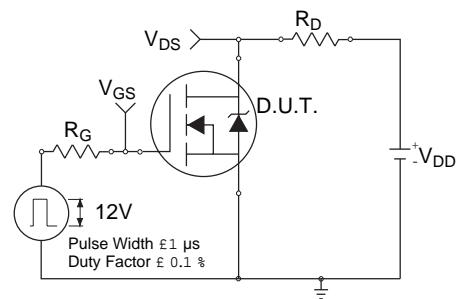


Fig 9a. Switching Time Test Circuit

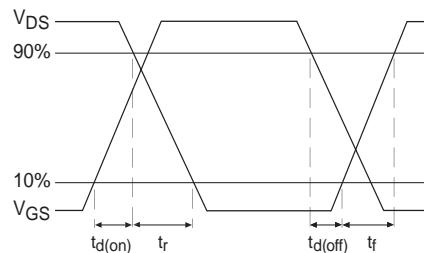


Fig 9b. Switching Time Waveforms

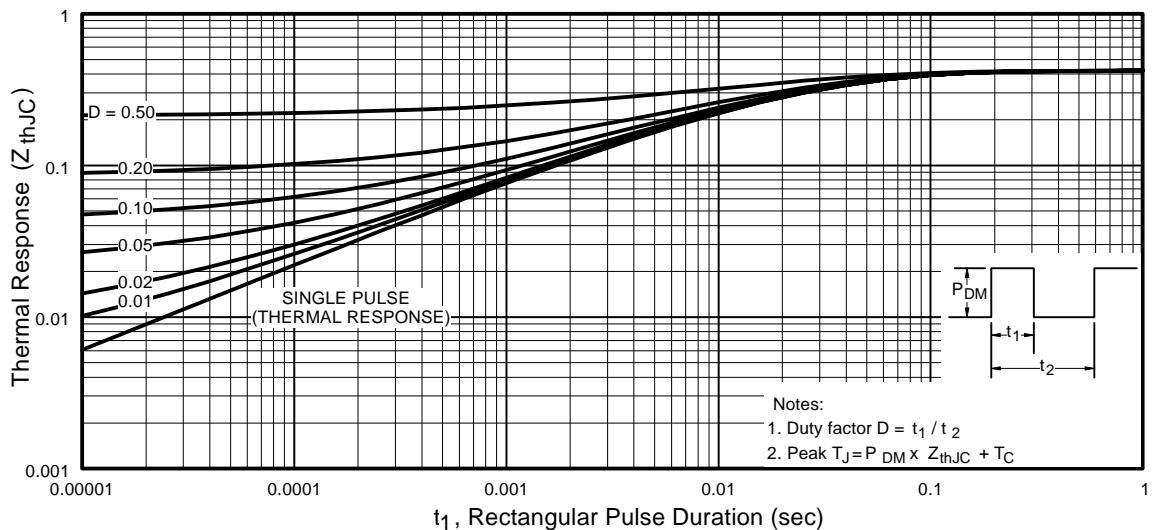


Fig 10. Maximum Effective Transient Thermal Impedance, Junction-to-Case

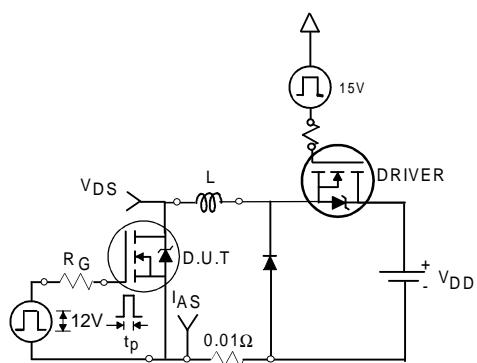


Fig 11a. Unclamped Inductive Test Circuit

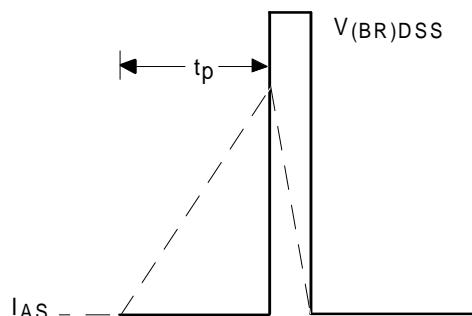


Fig 11b. Unclamped Inductive Waveforms

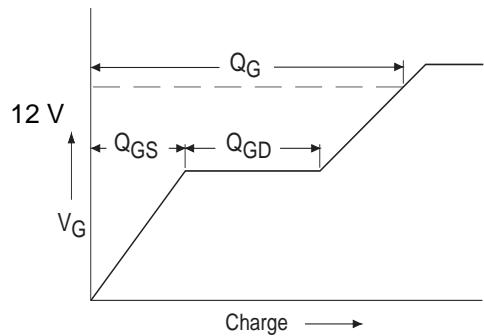


Fig 12a. Basic Gate Charge Waveform

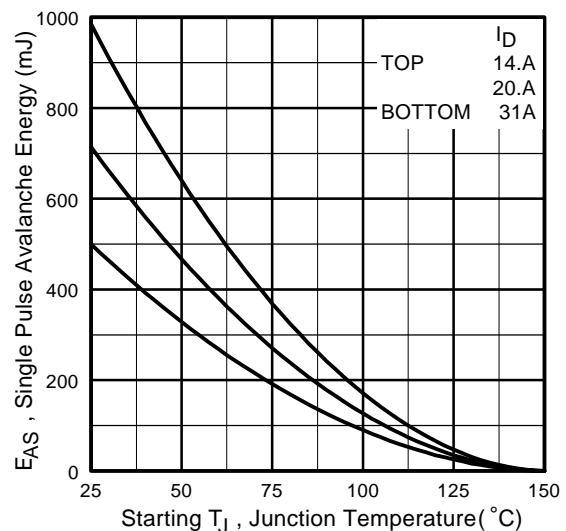


Fig 11c. Maximum Avalanche Energy Vs. Drain Current

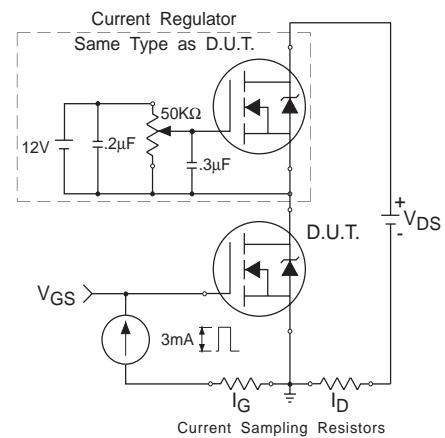
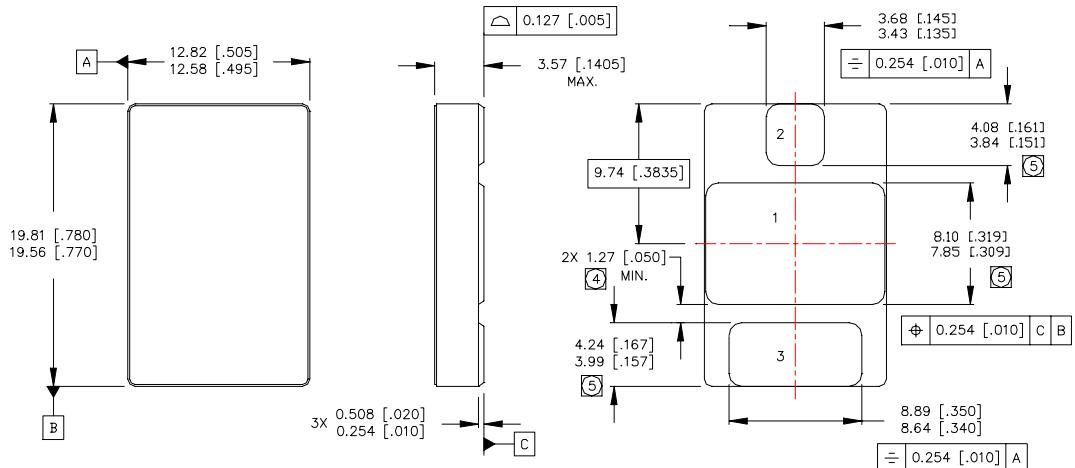


Fig 12b. Gate Charge Test Circuit

- ① Repetitive Rating; Pulse width limited by maximum junction temperature.
Refer to current HEXFET reliability report.
- ② @ $V_{DD} = 50V$, Starting $T_J = 25^\circ C$,
 $EAS = [0.5 * L * (I_L^2)]$
Peak $I_L = 34A$, $V_{GS} = 12V$, $25 \leq RG \leq 200W$
- ③ $ISD \leq 34A$, $dI/dt \leq 300A/\mu s$,
 $V_{DD} \leq BV_{DSS}$, $T_J \leq 150^\circ C$
Suggested $RG = 2.35W$
- ④ Pulse width $\leq 300 \mu s$; Duty Cycle $\leq 2\%$
- ⑤ **Total Dose Irradiation with V_{GS} Bias.**
12 volt V_{GS} applied and $V_{DS} = 0$ during irradiation per MIL-STD-750, method 1019, condition A.
- ⑥ **Total Dose Irradiation with V_{DS} Bias.**
 $V_{DS} = 0.8$ rated BV_{DSS} (pre-irradiation) applied and $V_{GS} = 0$ during irradiation per MIL-STD-750, method 1019, condition A.
- ⑦ This test is performed using a flash x-ray source operated in the e-beam mode (energy ~ 2.5 MeV), 30 nsec pulse.
- ⑧ All Pre-Irradiation and Post-Irradiation test conditions are **identical** to facilitate direct comparison for circuit applications.

Case Outline and Dimensions — SMD-3



NOTES:

1. DIMENSIONING & TOLERANCING PER ASME Y14.5M-1994.
2. CONTROLLING DIMENSION: INCH.
3. DIMENSIONS ARE SHOWN IN MILLIMETERS [INCHES].
4. DIMENSION INCLUDES METALLIZATION FLASH.
5. DIMENSION DOES NOT INCLUDE METALLIZATION FLASH.

LEAD ASSIGNMENTS

- | | |
|---|----------|
| 1 | = DRAIN |
| 2 | = GATE |
| 3 | = SOURCE |

SMD-3

International
IR Rectifier

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